

THEORY OF THE TIME-DEPENDENT CHILD-LANGMUIR SHEATH

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For simplicity, the plasma-wall transition layer is usually split into a presheath and a sheath region [1], and the sheath (especially for highly negative wall potentials) is further subdivided into two regions, namely the *Langmuir-Debye sheath*, where the electron density must still be taken into account (but drops rapidly), and the electron-free *Child-Langmuir sheath*, where the electron density is practically negligible [2]. In fact, the presheath-sheath interface, the *sheath edge*, represents the transition from the quasineutral presheath to the Langmuir-Debye sheath.

In the present paper we show that the problem of the time-dependent Child-Langmuir sheath can be solved in quite general form, and that it only remains to apply the general solution to a given particular physical situation. In an application of our general result, we consider the limiting case when the wall potential changes adiabatically.

We assume a collision-free sheath in front of an absorbing plane wall located at $z = 0$. The plasma, consisting of electrons and singly charged ions, occupies the half space $z < 0$. The ions are described by the hydrodynamic continuity and momentum equations

$$\frac{\partial n}{\partial t} + \frac{\partial}{\partial z} nu = 0, \quad \frac{\partial u}{\partial t} + u \frac{\partial u}{\partial z} = \frac{e}{m} E, \quad (1)$$

with the electric field $E = -\partial\varphi/\partial z$ satisfying Poisson's equation and Ampère's law,

$$\frac{\partial E}{\partial z} = 4\pi e (n - n_e), \quad \frac{\partial E}{\partial t} + 4\pi (enu + J_e) = 0. \quad (2)$$

Here, n and u are ion density and velocity, m is the ion mass, e is the magnitude of the electron charge, φ is the electric potential, and n_e and J_e are the electron density and

the electron current, respectively. Inserting n from Poisson's equation. into Ampère's law we find

$$\frac{\partial E}{\partial t} + u \frac{\partial E}{\partial z} = -4\pi(J_e + en_e u). \quad (3)$$

Further we assume that the ion velocity is much smaller than the electron one, $u \ll u_e = |J_e|/en_e$, and hence can be neglected, The main equations than acquire the form

$$\frac{\partial u}{\partial t} + u \frac{\partial u}{\partial z} = \frac{e}{m} E, \quad \frac{\partial E}{\partial t} + u \frac{\partial E}{\partial z} = -4\pi J_e. \quad (4)$$

In what follows, we assume that the time dependence of the problem is dictated by the ion dynamics, so that the characteristic time and space scales of the problem, $\Delta\tau$ and Δl , satisfy the inequality $V_{Te} \gg \Delta l/\Delta\tau$, where $V_{Te} = \sqrt{T_e/m_e}$ is the electron thermal velocity. For the electron distribution function we use the general solution of the Vlasov equation,

$$f_e = \bar{f}_e \left(\frac{m_e v^2}{2} - e\varphi(z, t) \right) \Theta \left(\sqrt{\frac{2e}{m_e} \{|\varphi_w(t)| - |\varphi(z, t)|\}} + v \right), \quad (5)$$

where $\varphi_w(t) (\leq 0)$ is the time-dependent negative potential on the wall, \bar{f}_e is an arbitrary function of its argument, and $\Theta(x)$ is the Heaviside step function describing the cut-off due to electron absorption at the wall. To be specific, we choose for $\bar{f}_e(s)$ the Maxwell-Boltzmann distribution function, $\bar{f}_e(s) \propto \exp(-s/T_e)$. Then for the electron current we obtain

$$J_e(t) = -\sqrt{\frac{2}{\pi}} en_0 V_{Te} \frac{\exp\left(-\frac{e}{T_e} |\varphi_w(t)|\right)}{1 + \operatorname{erf}\left\{\sqrt{\frac{e}{T_e}} |\varphi_w(t)|\right\}}, \quad (6)$$

where n_0 is the unperturbed electron density, $n_e(z, t) \rightarrow n_0$ and $\varphi(z, t) \rightarrow 0$ for $z \rightarrow -\infty$, and $\operatorname{erf}(x)$ is the error function.

Note that the electron current (6) depends only on time. By means of the variable transformation $z = z(E, t)$ and $u(z, t) = u(E, t)$ we find the general solution of Eqs. (4) in the form

$$\begin{aligned} z &= z(E, t) = \frac{e}{m} \int^t dt' \int^{t'} dt'' \left\{ E + 4\pi \int_{t''}^t dt''' J_e(t''') \right\} + \\ &+ t \cdot \Phi_1 \left(E + 4\pi \int^t dt' J_e(t') \right) + \Phi_2 \left(E + 4\pi \int^t dt' J_e(t') \right), \end{aligned} \quad (7)$$

where $\Phi_1(x)$ and $\Phi_2(x)$ are arbitrary functions which must be defined according to the initial and boundary conditions of the concrete problem considered. However, the absence

of a sharp sheath edge and the ignorance of accurate boundary (or initial) conditions for the Child-Langmuir sheath compel us to make simplifications at the definition of these arbitrary functions. When formulating the Child-Langmuir law, the electric field and the ion velocity at the entrance of the electron-free sheath are usually neglected due to their smallness in comparison with their values inside of the sheath [2, 3, 4]. In the present work, this condition is relaxed by assuming a suitable electric-field value $E_0 = \text{const}$, from which on the electron density is neglected. Obviously, the position where $E = E_0$, z_0 , will change in time. The interval $(0, z_0(t; E_0))$ we interpret as the width of the Child-Langmuir sheath.

For the further calculations it is convenient to introduce the auxiliary function $F(t)$, defined by the relation $J_e(t) = -\partial F(t)/\partial t$, and the new variable E' instead of t' :

$$E' = E + 4\pi F(t) - 4\pi F(t'). \quad (8)$$

The general solution (7) then assumes the form

$$\begin{aligned} z(t) = & z_0 \{t \{E_0 - E - 4\pi F(t)\}; E_0\} \\ & + \frac{e}{m} \int_{E_0}^E \frac{dE'}{4\pi J_e \{t' \{E' - E - 4\pi F(t)\}\}} \int_{E_0}^{E'} \frac{E'' dE''}{4\pi J_e \{t'' \{E'' - E - 4\pi F(t)\}\}} \quad (9) \\ & - u_0 \{t \{E_0 - E - 4\pi F(t)\}; E_0\} \cdot \int_{E_0}^E \frac{dE'}{4\pi J_e \{t' \{E' - E - 4\pi F(t)\}\}}, \end{aligned}$$

where $t' \{E' - E - 4\pi F(t)\}$ is the solution of Eq. (8).

For the limiting case of an adiabatically changing wall potential and electron current (6) ($\omega_{pi}\Delta\tau \gg 1$, with ω_{pi} the ion plasma frequency), we can find from (8) the explicit relation

$$t' \simeq t - \frac{E' - E}{4\pi J_e(t)}. \quad (10)$$

Then from (9) we find

$$z - z_0 \{t; E_0\} \simeq \frac{e}{m} \frac{1}{6(4\pi J_e(t))^2} \left\{ E^3 + \frac{9}{4} \frac{1}{4\pi J_e^2(t)} \frac{\partial J_e(t)}{\partial t} E^4 \right\}, \quad (11)$$

where the second term on the right-hand side describes the small deflection due to the time-dependence of the wall potential, i.e.,

$$\left| E \frac{1}{4\pi J_e^2(t)} \frac{\partial J_e(t)}{\partial t} \right| \approx \left| \frac{E}{4\pi J_e(t) \cdot \Delta\tau} \right| \ll 1. \quad (12)$$

Since solving Eqs (9) and (11) for finite E_0 promises to be quite complicated, we content ourselves here with the usual approximation, $E_0 \rightarrow 0$. For the potential in the sheath we then find

$$\begin{aligned} \frac{e}{T_e} \Delta |\varphi(z, t)| &= \frac{e}{T_e} \{ |\varphi(z, t)| - |\varphi(z_0, t)| \} \\ &= 2 \left(\frac{3}{4} \right)^{4/3} \left\{ \frac{J_e(t)}{en_0 v_s} \right\}^{2/3} \left\{ \left(\frac{z - z_0}{\lambda_{De}} \right)^{4/3} \right. \\ &\quad \left. + \frac{6}{5} \left(\frac{3}{4} \right)^{1/3} \frac{1}{\omega_{pi} J_e(t)} \frac{\partial J_e(t)}{\partial t} \left\{ \frac{J_e(t)}{en_0 v_s} \right\}^{-1/3} \left(\frac{z - z_0}{\lambda_{De}} \right)^{5/3} \right\}, \end{aligned} \quad (13)$$

where $\varphi(z_0, t)$ is the potential at the sheath entrance.

From (13) follows the remarkable result that for slowly changing wall potential (i. e., $|(\omega_{pi} J_e(t))^{-1} \partial J_e(t) / \partial t| \ll 1$) the Child-Langmuir contains, besides the usual term proportional to $(z - z_0)^{4/3}$, an additional correction term proportional to $(z - z_0)^{5/3}$.

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References

- [1] K.-U. Riemann, *Theory of the Plasma-Sheath Transition*, General Invited Lecture, XXIVth ICPIG, Warsaw, 1999; J. Tech. Phys. **41** (1), Special Issue, 89–121 (2000).
- [2] C. D. Child, Phys. Rev. **32**, 492 (1911).
- [3] K.-U. Riemann and L. Tsengin, J. Appl. Phys. **90**, 5487 (2001).
- [4] F. F. Chen, *Introduction to Plasma Physics and Controlled Fusion*, Vol.1, Second ed. (Plenum Press, NY, 1990), p.294.